

**Electronic Filing System (EFS) Data**  
**Electronic Patent Application Submission**  
**USPTO Use Only**

EFS ID: 60295  
Application ID: 10709406  
Title of Invention: METHOD TO REDUCE  
PHOTORESIST PATTERN  
COLLAPSE BY CONTROLLED  
SURFACE MICROROUGHENING  
First Named Inventor: Colin Brodsky  
Domestic/Foreign Application: Domestic Application  
Filing Date: 2004-05-03  
Effective Receipt Date: 2004-05-03  
Submission Type: Utility Patent Filing  
Filing Type: new-utility  
Confirmation number: 3405  
Attorney Docket Number: FIS920030360



Total Fees Authorized: 810.0  
Payment Category: Deposit Account  
Deposit Account Number: 90458  
Deposit Account Name: Todd M. C. Li  
RAM Payment Status: RAM has not been processed

Digital Certificate Holder: cn=Todd M. C. Li,ou=Registered Attorneys,ou=Patent and Trademark  
Office,ou=Department of Commerce,o=U.S. Government,c=US  
Certificate Message Digest: 97486abcc08b5c7de2e51a0ec65ed7f6d4b110a6

PATENT APPLICATION SERIAL NO. \_\_\_\_\_

U.S. DEPARTMENT OF COMMERCE  
PATENT AND TRADEMARK OFFICE  
FEE RECORD SHEET

05/04/2004 MGE BREM1 00000033 090458 10709406

01 FC:1001 770.00 DA

PTO-1556  
(5/87)